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| <b>Search Notes</b><br> | <b>Application/Control No.</b><br>10/802,162 | <b>Applicant(s)/Patent under Reexamination</b><br>LEE, HWAL RIM |
|  | <b>Examiner</b><br>Paulos M. Natnael         | <b>Art Unit</b><br>2622   |